

Direct laser writing by two photon polymerization

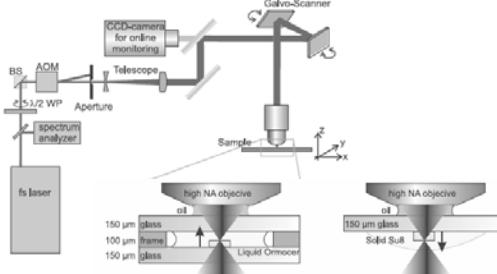
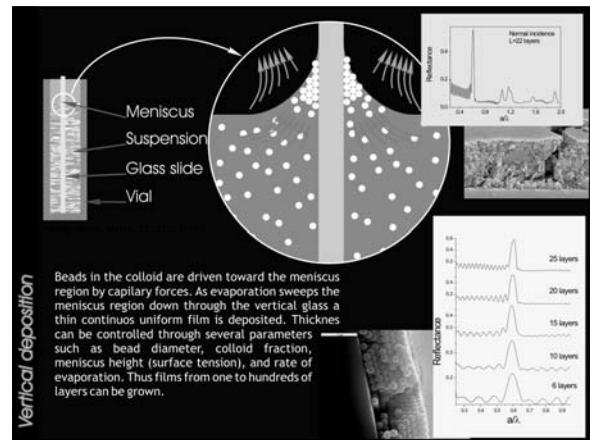
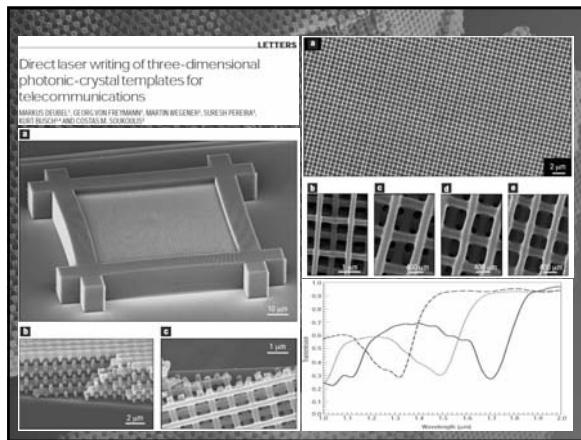
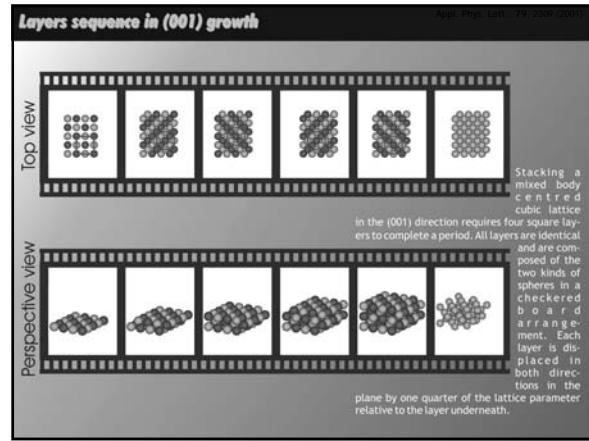
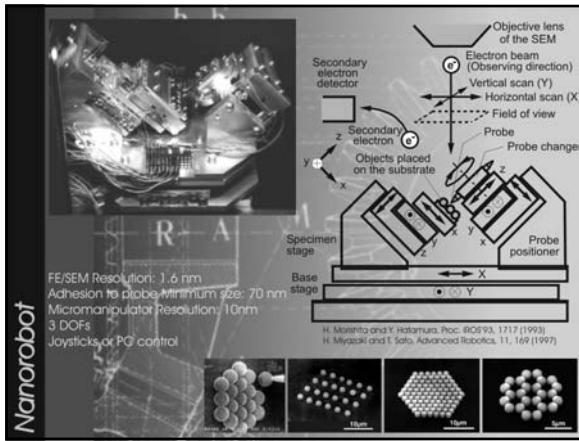
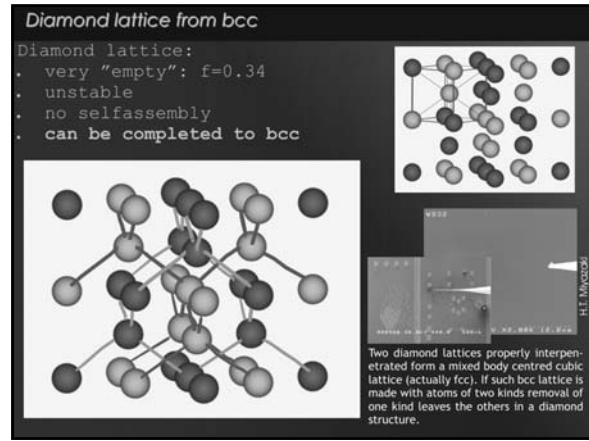
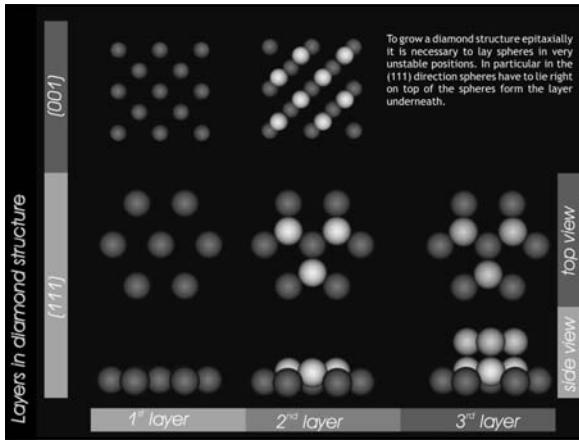
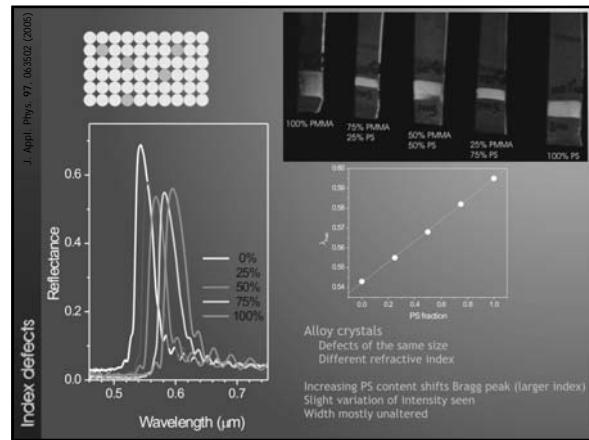
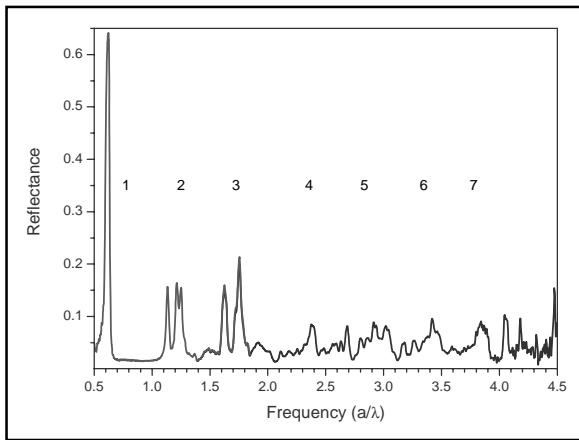
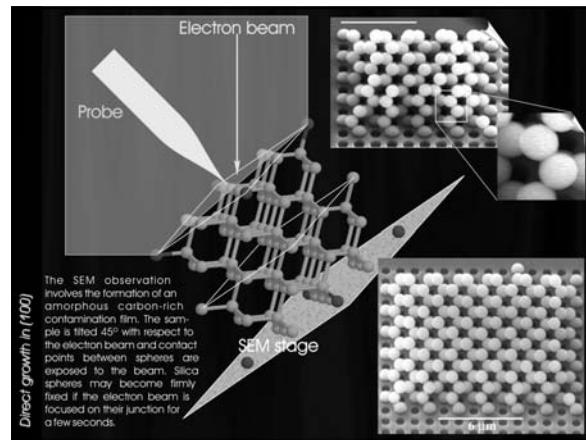
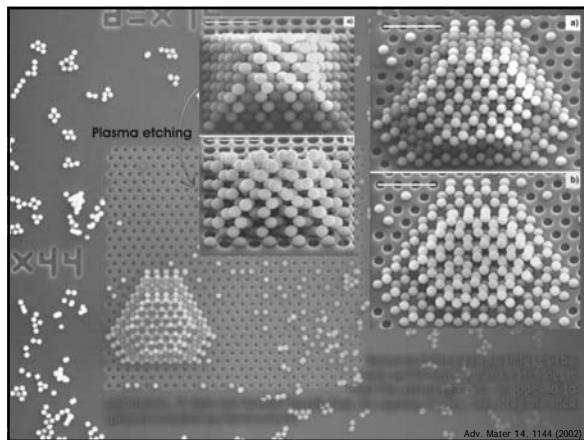
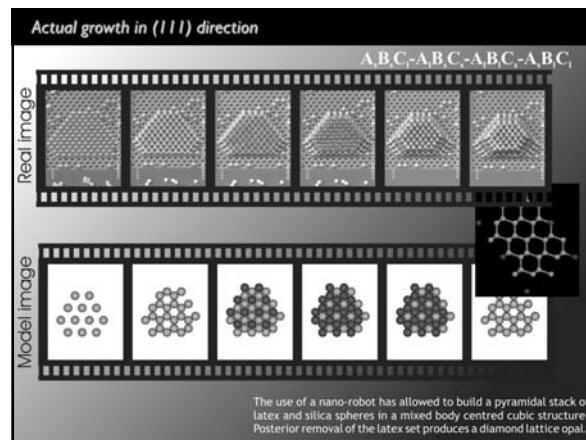
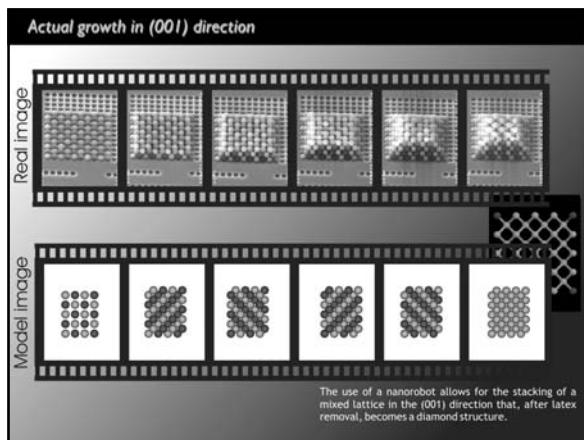
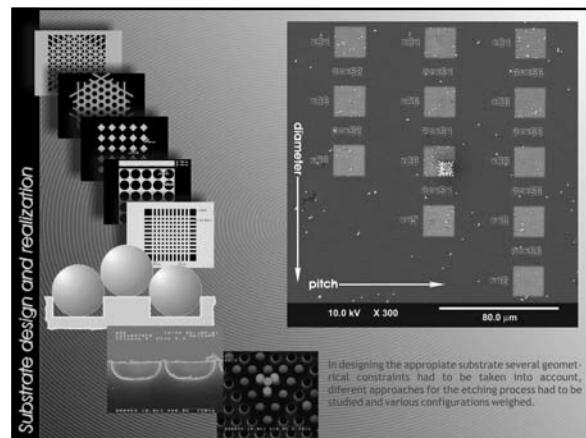
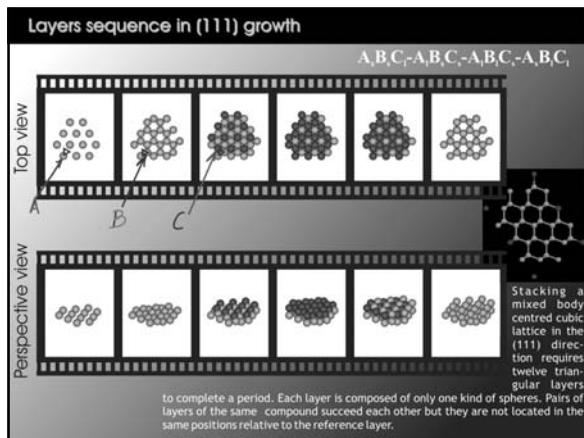
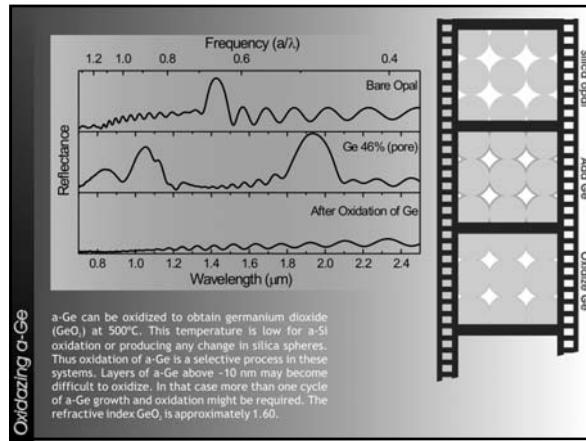
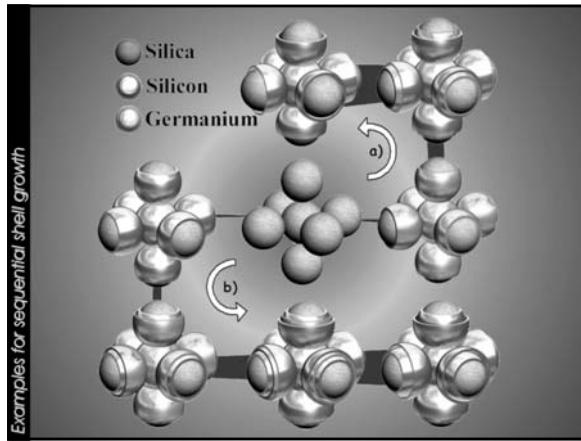
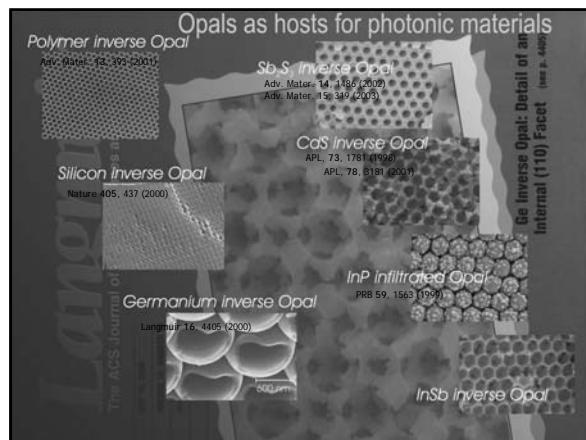
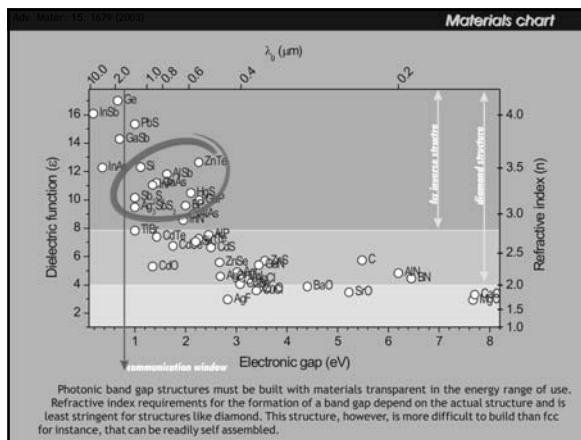
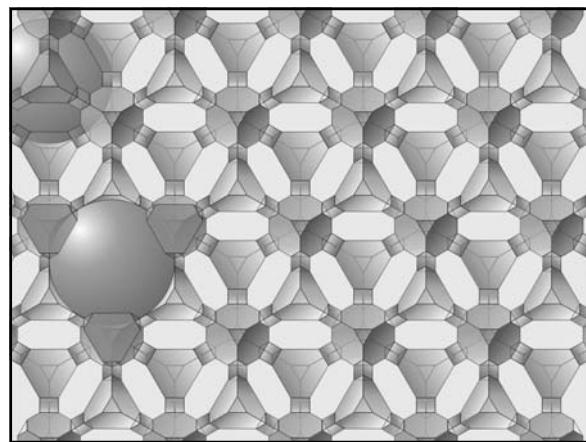
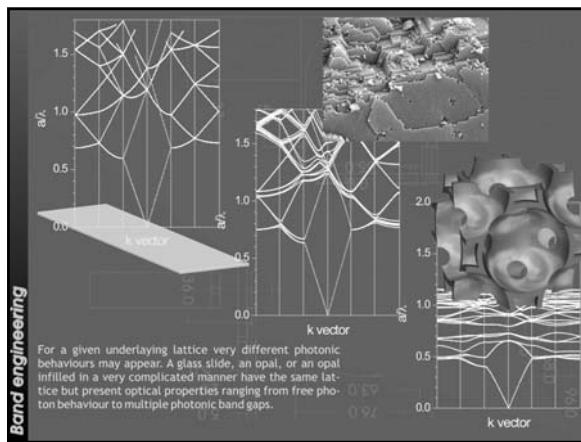


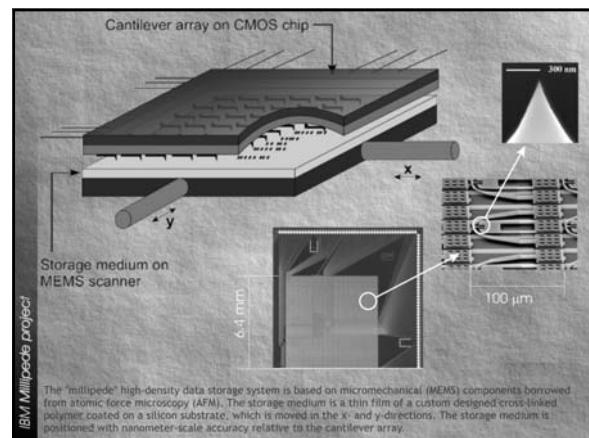
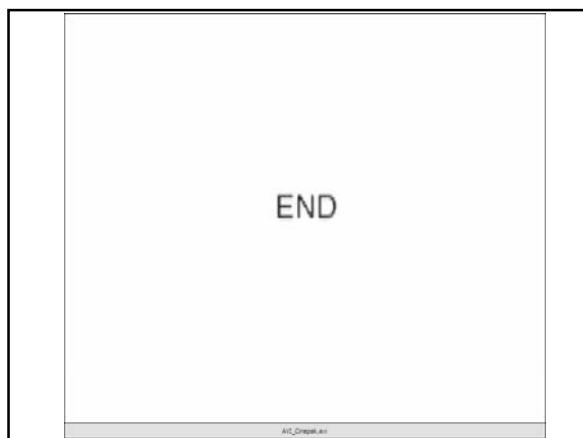
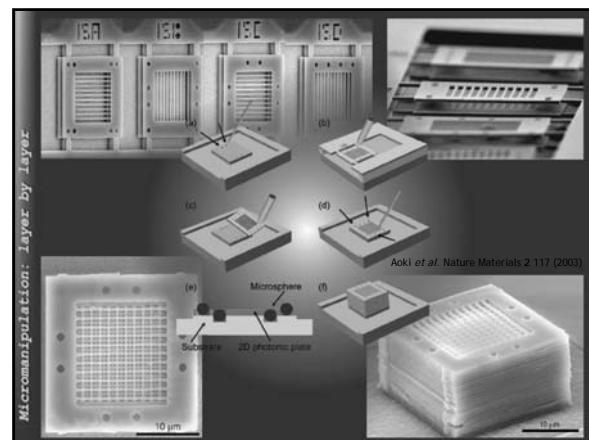
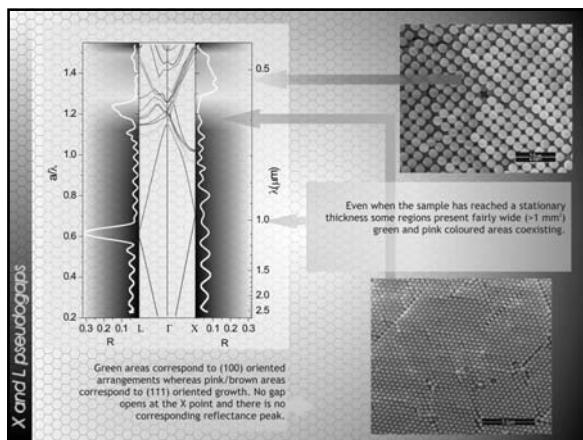
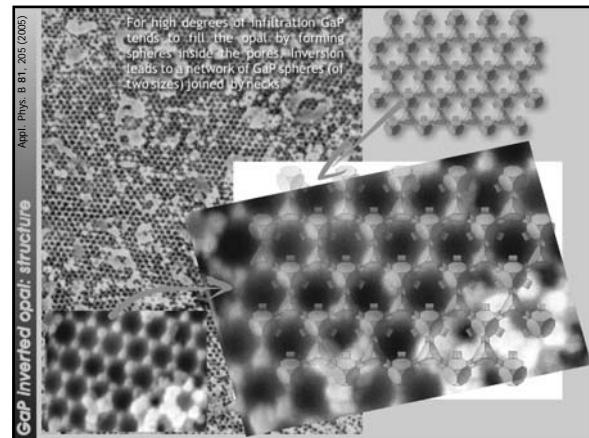
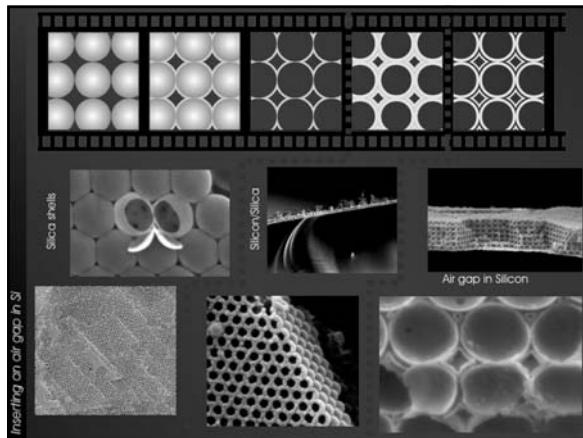
Fig. 1. Principle setup for the fabrication of 3D structures by 2PP. A waveplate (WP) together with a polarizing beamsplitter is used as an attenuator, an acousto-optical modulator (AOM) in combination with an aperture as a fast shutter. The beam is expanded by a telescope and then coupled into an x-y galvo scanner. The sample is mounted on a 3D piezo stage for positioning in all directions. A CCD camera placed behind a dichroic mirror is used for online monitoring of the 2PP process.











**CAST**

Grupo de Cristales Fotónicos del  
Instituto de Ciencia de Materiales de Madrid

Marta Ibisate  
Martín López  
Lola Golmayo  
Alvaro Blanco  
Ainhoa Altube  
P. David García  
Riccardo Sapienza

**FUNDING**

MEC: MAT2003-01237, NAN2004-08843  
EU: IST-511616 PhOREMOST, HI2004-0367  
ESF: COST P11